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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/623,004	07/17/2003	Alex Ka Tim Poon	PA0362-US / 11269.60	4132	
75	7590 08/09/2005			EXAMINER	
The Law Office of Steven G. Roeder			RUTLEDGE, DELLA J		
5560 Chelsea Avenue La Jolla, CA 92037		ART UNIT	PAPER NUMBER		
			2851		

DATE MAILED: 08/09/2005

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)				
	10/623,004	POON ET AL.				
Office Action Summary	Examiner	Art Unit				
	D. Rutledge	2851				
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the d	correspondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a repl - If NO period for reply is specified above, the maximum statutory period of Failure to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be tir y within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from t, cause the application to become ABANDONE	nely filed rs will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on 25 A	pril 2005.					
	action is non-final.					
•	3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Disposition of Claims						
4) ⊠ Claim(s) 1-19 and 21-61 is/are pending in the state 4a) Of the above claim(s) is/are withdraw 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) 1-19 and 21-61 is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/o	wn from consideration.					
Application Papers	,					
9) The specification is objected to by the Examine	ur .					
· · · · · · · · · · · · · · · · · · ·	 epted or b)⊡ objected to by the	Examiner.				
Applicant may not request that any objection to the						
Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex		•				
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Applicati rity documents have been receive u (PCT Rule 17.2(a)).	on No ed in this National Stage				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary					
 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 10/03. 	Paper No(s)/Mail Do 5) Notice of Informal F 6) Other:	Patent Application (PTO-152)				

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DETAILED ACTION

Claim Rejections - 35 USC § 112

1. Claims 49 and 55 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The claims are purported to be a method of making a wafer, but there are no steps defined to make the method.

Claim Rejections - 35 USC § 103

- 2. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 3. Claims 1 10, 16 25, 30 33, 37 46, 48, 56 61 are rejected under 35 U.S.C. 103(a) as being unpatentable over Krenzer (US 5,757,160).

The reference discloses a measuring system in an exposure apparatus comprising a stage 10 that is positioned to exposure a pattern onto a substrate 12 on the stage 10. The measurement system has a laser source 34, a first path 37; a penta-prism 36 that redirects the beam at a 90° angle to the first path and has a reflector 32 that is arranged as claimed and directs the beam back to the penta-prism. The reference differs from the applicant invention in that on one source is used to measure with a plural interferometer system that measure plurality of displacement along plural axes. One of ordinary skill in the art would have recognized that while source may be used, multiple

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source may be used an reduce the complexity of design. The reference is able to produce an accurate measure because the system is less sensitive to rotation about a third angle (see abstract, col. 6, lines 48 – 53).

The reference does not disclose the calculating the position or displacement, but those of ordinary skill in the art would know how to use the Interferometry system.

4. Claims 11 – 15, 26 – 29, 34 – 36, 47, 50 – 54 are rejected under 35

U.S.C. 103(a) as being unpatentable over Kreuzer (US 5,757,160) as applied to claims

1, 16, 19, 24, 25, 32, 33, 40 above, and further in view of Takagi et al. (US 5,469,260).

The primary reference does not disclose a shield to cover the measuring light beam.

Takagi et al. teach covering/shield 10y, 12y, 30y, 31y, 40y the measuring measuring to prevent temperature variation from causing an inaccurate measurement. The shield is attached to the substrate stage.

Conclusion

5. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Ueda UUS 6,166,812) and Kato et al. (US 6,049,372) provide a measuring system that is accurate even if there is rotation about an axis; and McMurtry et al. (US Pub. No. 2002/0122178) disclose shielding the measurement beam.

Response Data

Any inquiry concerning this communication or earlier communications from the examiner should be directed to D. Rutledge whose telephone number is (571) 272-2127. The examiner can normally be reached on Mon - Thurs, 6:00 AM - 4:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Judy Nguyen can be reached on (571) 272-2258. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

D. Rutledge
Primary Examiner
Art Unit 2851

dr 8/8/05